In the claims:

Please rewrite claims 1-3, 5, 6, 8-12, 14, 15, 17 and 21 as follows. A marked-up version of claims 1-3, 5, 6, 8-12, 14, 15 and 17 is attached to show the amendments.

1. (Amended) A photo and thermally labile siloxane polymer which undergoes transformation to SiO_2 -rich films by the release of unsaturated hydrocarbons and protonated byproducts) obtained from the hydrolysis and condensation polymerization of an organosilane containing an alkyl group substituted in the position β to silicon, the organosilane having the general formula:

PM

where n is 1

 $(RCH_2)_n SiX_{(4-n)}$

where n is 1 or 2;

X is a halogen selected from the group consisting of chlorine, bromine, fluorine, and iodine; or an alkoxy selected from the group consisting of methoxy, ethoxy and propoxy substituents; and

R is an alkyl group having at least one but not more than two substituents in the position β to silicon that are electronegative; and wherein said siloxane polymer contains silanol groups.

- 2. (Amended) The siloxane polymer of claim 1 wherein, in the general formula for the organosilane, R is a methyl group or ethyl group having at least one but not more than two substituents in the position β to silicon selected from the group consisting of bromine, fluorine, iodine, hydroxy, methoxy, ethoxy, and acetoxy.
- 3. (Amended)) A photo and thermally labile siloxane polymer which undergoes transformation to SiO_2 -rich films by the release of unsaturated hydrocarbons and protonated byproducts, obtained from the hydrolysis and condensation polymerization of an organosilane containing a β -substituted alkyl group, the organosilane having the general formula:

pm

where n is 1 or 2;

 $R_n SiX_{(4-n)}$

BI

X is a halogen selected from the group consisting of chlorine, bromine, fluorine, and iodine; or an alkoxy selected from the group consisting of methoxy, ethoxy and propoxy substituents; and

R is an alkyl group having at least one but not more than two β -substituents that are electronegative and at least one but not more than two α -substituents on the β -substituted alkyl group, the α -substituent being selected from the group consisting of chlorine, bromine, fluorine, iodine, hydroxy, methoxy, ethoxy, and acetoxy; and wherein said siloxane contains silanol groups

5. (Amended) The siloxane polymer of claim 1 wherein, in the general formula for the organosilane, n is 1;

X is a halogen selected from the group consisting of chlorine and bromine or an alkoxy selected from the group consisting of methoxy and ethoxy substituents; and

R is a methyl group having at least one but not more than two substituents selected from the group consisting of bromine, fluorine, hydroxy, methoxy, and acetoxy.

6. (Amended) A photo and thermally labile siloxane polymer which undergoes transformation to SiO₂-rich films by the release of unsaturated hydrocarbons and protonated byproducts, obtained from the hydrolysis and condensation polymerization of an organosilane containing a β-substituted alkyl group the organosilane having the general formula:

NIN

vhere n is 1:

 $R_n SiX_{(4-n)}$

X is a halogen selected from the group consisting of chlorine and bromine, or an alkoxy selected from the group consisting of methoxy and ethoxy substituents; and

R is an ethyl group having at least one but not more than two β -substituents selected from the group consisting of bromine, fluorine, methoxy, and acetoxy and at least one but not more than two α -substituents on the β -substituted ethyl group, the α -substituent being selected from the group consisting of chlorine, bromine, fluorine, hydroxy, methoxy, and acetoxy;

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- 8. (Amended) The siloxane polymer of claim 1 wherein the siloxane polymer is obtained from the hydrolysis and condensation polymerization of a β -substituted ethyltrichlorosilane, wherein the β -substituent is non-halogenated.
- 9. (Amended) The siloxane polymer of claim 1 wherein the siloxane polymer contains at least about five up to about 75 silanol groups per 100 silicon atoms.
- 10. (Amended) The siloxane polymer of claim 1 wherein the siloxane polymer contains about 20 to about 50 silanol groups per 100 silicon atoms.
- 11. (Amended) The siloxane polymer of claim 1 wherein the siloxane polymer is obtained from homopolymerization of the organosilane.
- 12. (Amended) The siloxane polymer of claim 1 wherein the siloxane polymer is obtained from copolymerization of the organosilane with an alkoxysilane.
- 14. (Amended) The siloxane polymer of claim 1 which further comprises a siloxane polymer obtained from copolymerization of the organosilane with a hydride-functional silane selected from the group consisting of trichlorosilane and triethoxysilane.
- 15. (Amended) The siloxane polymer of claim 1 which further comprises a siloxane polymer obtained from copolymerization of the organosilane with an organotrichlorosilane selected from the group consisting of ethyltrichlorosilane, methyltrichlorosilane and phenyltrichlorosilane.
- 17. (Amended) The siloxane polymer of claim 16 wherein the siloxane polymer is extracted from the aqueous medium with an organic solvent.

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21. (Amended) The siloxane polymer of claim 1 wherein, in the general formula for the organosilane, R is a methyl group having at least one but not more than two acetoxy substituents.

Please add the following new claims:

22. (New) A photo and thermally labile siloxane polymer without fillers of the structure [CICH₂CH₂SiO(OH)]_p[CICH₂CH₂SiO_{1.5}]_q, in which the ratio of p:q is from 1:5 to 1:1, which undergoes transformation to SiO₂-rich films by the release of unsaturated hydrocarbons and protonated byproducts, obtained from the hydrolysis and condensation of an organosilane having the general formula:

where n is 1 or 2 and m is 0 or 1;

X is a halogen selected from the group consisting of chlorine, bromine, fluorine, and iodine; or an alkoxy selected from the group consisting of methoxy, ethoxy and propoxy substituents; and

R' is any substituted of unsubstituted alkyl group.

23. (New) A photo and thermally labile siloxane polymer which undergoes transformation to \$iO₂-rich films by the release of unsaturated hydrocarbons and protonated byproducts, obtained from the hydrolysis and condensation polymerization of an organosilane containing an afkyl group substituted in the position β to silicon, the organosilane having the general formula:

 $(RCH_2)_nSiX_{(4-n)}$

where n is 1 or 2:

X is a halogen selected from the group consisting of chlorine, bromine, fluorine, and iodine; or an alkoxy selected from the group consisting of methoxy, ethoxy and propoxy substituents; and